

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re application of: Chan, et al.

Serial No.: 10/035,387

Filed: December 28, 2001

For: SURFACE DISTORTION

COMPENSATED PHOTOLITHOGRAPHY

Group Art Unit: 2873

Examiner: Unknown

INFORMATION DISCLOSURE STATEMENT

Commissioner For Patents Washington, DC 20231

Sir:

Pursuant to the provisions of 37 C.F.R. § 1.97, Applicant hereby makes of record the references set forth in the attached modified form PTO-1449. No inference should be made that the cited references are in fact material, are in fact prior art, or that no better art exists. The cited patents are listed in numerical order and not in any order based on their pertinence.

Pursuant to 37 C.F.R. §1.98(d), no copies of the cited references are enclosed since the references were provided in the parent application, U.S. Serial No. 09/918,732 and in Serial No. 09/728,691 and Serial No. 09/718,619. However, Cite Numbers A19, A20, A21 and A23 have not been disclosed in this application or any related application, therefore copies of those patents are enclosed herewith.

It is requested that the Examiner fully consider the cited references and that they be cited on the front of any patent issuing from this application.

An early action on the merits is respectfully requested.

Respectfully submitted,

David M. O'Dell Reg. No. 42,044

3-8-02 Dated: HAYNES AND BOONE, LLP 901 Main Street, Suite 3100 Dallas, Texas 75202-3789 Telephone: 214/651-5262 Facsimile: 214/651-5940

File: 22397.266

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U. S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE In place of PTO-1449 Complete if Known MAY 2 0 2002 Form Application Number 10/035,387 INFORMATION DISCLOSURE Filing Date 12/28/2001 STATEMENT BY APPLICANT (use as many sheets as necessary) Applicant(s) Kin Foong Chan et al. Art Unit **Examiner Name** Unknown SHEET 1 OF 2 Attorney Docket Number 22397.266

	U. S. PATENT DOCUMENTS				
Examiner's Initials	Cite No.	Document Number	Publication Date	Name of Patentee or Applicant of Cited Document	
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	A2	4,126,812	11/21/78	Wakefield	
	A3	4,774,047	05/10/88	Okamoto et al.	
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	A7	5,106,455	04/21/92	Jacobsen et al.	
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FOREIGN PATENT DOCUMENTS					
Examiner's Initials	Cite No.	Foreign Patent Document (Country Code - Number - Kind)	Publication Date	Patentee or Applicant of Cited Document	Translation yn
	B1	PCT 9110170	11/07/91		
	B2	EP 0552953	28/07/93		

OTHER PRIOR ART				
Examiner' s initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article, title of the item, date, page(s), volume-issue number(s), publisher, city/country where published		
	C1	Dr. John R. Carruthers and Dr. James A. Glaze/TWO EXPERTS ON THE FRONTIERS OF LITHOGRAPHY/Insights & Enterprise/June, 2000/pages 82-83.		
	C2	"New Multi-EB Direct Write Concept for Maskless High Throughput", Canon SubMicron Focus, Volume 5, Summer 2000		
	СЗ	Sandstrom and Odselius, "Large-Area High Quality Photomasks", Micronic Laser Systems, published by SPIE, Volume 2621, 1985, pgs. 312-318		
	C4	Singh-Gasson, Sangeet et al., "Maskless Fabrication of Light-Directed Oligonucleotide Microarrays Using a Digital Micromirror Array, Volume 17, No. 10, October 1999, pgs. 974-978		
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Examiner	Date	
Signature	Considered	

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include a copy of this form with next communication to applicant.

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